## **TECHNICAL SPEC FOR Track system**

System Model: TEL Clean Track Mk8

**Tool status :** 

The tool, inclusive photoresist pumps, and the bypack units have been flushed and cleaned with solvent/DI water, and dry cleaned with CCA. The solvent lines (HMDS, Resist, thinner, developer have been disconnected from the tool), as well as the electric power supply lines. The bypacks of the tool are situated in the basement under the fab. The water cooling line and signal cables are still connected between process unit and bypack. Decommissioning was done by trained Litho technicians.

Specific Model: MD715691

Wafer size: 6 inch

Wafer type: Jeida flat

Wafer flow:

Number coater/developer modules: 2C2D (1C operational)

Inline system: Yes

Resists / Coaters: 2 (mini)

E2 Develop nozzle kits: 2

RRC Pumps & kits:

Dual-stream nozzles / Developer: no

Solvent & developer auto supply systems: Yes

**Temperature / Humidity controller: Yes** 

Configuration/layout of each block:

GEM: yes

AVG:

HMDS Bubblers: Venturi

Power supply: 208 V, 3 Phase, AC Transformer:

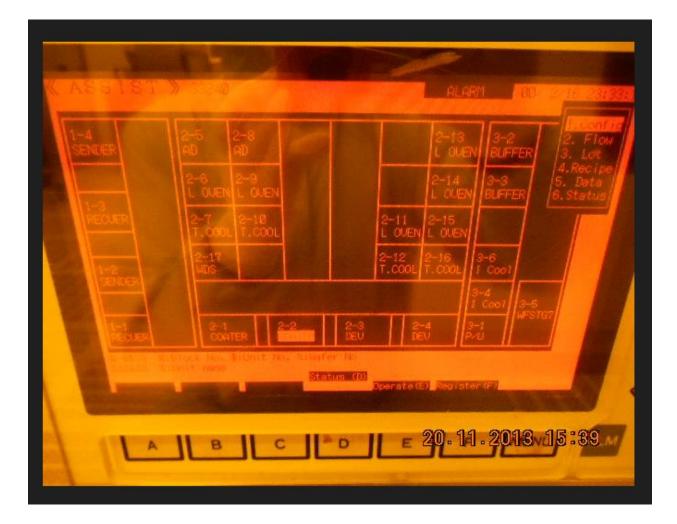
Vintage: 1995

Missing parts: none

Defected parts: none

Operating system:

COATER 6			
MD715691			
Nov-95			
Mk 8			
PB			
MK8Z2.30			
M8400829.00			
M8400829.00			
M8400829.00			
FC-9801F model 1			
FC-9801F Model 1			
I/O data Silicon disk			
External Logitec LFD-331 BAD			



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6	STG 1-4 STG 1-3 STG 1-2 STG 1-1	AD 2-5 AD HP 2-6 HP COL2-7 COL2 CWDS2-17 COAT 2-1	2-8 2-9 2-10 COAT 2-2	HP COL DEV 2-3	DEV	3-2	
	BESEZ						

## Photos to Collect

- All 4 sides
- Close up of each module (opened up)
- Inside all cabinets
- Chemical cabinets opened up
- Serial plate
- Serial plate of the laser
- Spare parts, manuals (if any)